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In re Application of:

Mak et al.

Patent No.: 6,849,545

Issued:

February 1, 2005

Serial No.: 09/885,609

Filed:

June 20, 2001

For:

SYSTEM AND METHOD TO

FORM A COMPOSITE FILM

STACK UTILIZING

SEQUENTIAL DEPOSITION

TECHNIQUES

Certificate of Correction Branch Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Group Art Unit: 2818

Examiner:

Renee R. Berry

CERTIFICATE OF MAILING

37 CFR 1.8

I hereby certify that this correspondence is being deposited on 2006 with the United States Postal Service as , 2006 with the United States Postal Service as First Class Mail in an envelope addressed to: Certificate of Correction Branch, Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

Dear Sir:

REQUEST FOR CORRECTED PATENT

Attached is a certificate of correction for correcting several errors throughout the printed patent. However, because of the nature of the errors, applicants request that the Director issue a corrected patent, if appropriate, in lieu of the certificate of correction (MPEP §1480; 35 USC 254 and 37 CFR 1.322(b)).

Some of the missing references were cited by the Applicant in an Information Disclosure Statement filed on March 29, 2002. It appears that these references were lost, and thus they do not appear on the printed patent. Attached is a copy of the PTO-1449 as originally submitted on March 29, 2002, as well as a copy of the stamped return receipt postcard showing evidence that the Patent Office acknowledged receipt of this Information Disclosure Statement.

Some of the missing references were cited by the Applicant in an Information Disclosure Statement filed on May 2, 2002. It appears that these references were

SEP 1 3 2000

lost, and thus they do not appear on the printed patent. Attached is a copy of the PTO-1449 as originally submitted on May 2, 2002, as well as a copy of the stamped return receipt postcard showing evidence that the Patent Office acknowledged receipt of this Information Disclosure Statement.

The missing reference US-2003/0089308 was initialed by the examiner on July 10, 2004 in the Notice of Allowability dated August 2, 2004. Attached is a copy of the PTO/SB/08a showing the missing reference initialed by the examiner.

The remaining missing references were cited by the examiner in the Office Action dated March 14, 2003. Attached is a copy of the PTO-892 showing the missing references.

The drawings that appear in the printed patent are the informal drawings. Formal drawings were submitted on November 27, 2001, which appear to have been lost or overlooked. Attached is a copy of the transmittal form, transmittal letter, and formal drawings as submitted on November 27, 2001, as well as a copy of the stamped return receipt postcard showing evidence that the Patent Office acknowledged receipt of the drawings.

Applicants submit that the errors mentioned above were not made by the applicants, but were made during the printing of the patent. Accordingly, the Applicants believe that no fee is due for the corrected patent at this time.

Respectfully submitted,

Keith M. Tackett

Registration No. 32,008

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Houston, TX 77056

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Agent for Applicant(s)

Since the species

Page 2

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UNITED STATES PATENT AND TRADEMARK OFFICE

CERTIFICATE OF CORRECTION

PATENT NO.: 6,849,545 Page <u>1</u> of <u>18</u>

APPLICATION NO.: 09/885,609

DATED: Feb. 1, 2005

INVENTOR(S): Alfred W. MAK, Mei CHANG, Jeong Soo BYUN, Hua CHUNG, Ashok SINHA, Moris KORI

It is certified that error appears in the above-identified patent and that said Letters Patent are hereby corrected as shown below:

On the Cover of the Patent

Item [56], References Cited, U.S. PATENT DOCUMENTS: Please include the following references:

4,486,487	12/1984	Skarp 428/216
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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.: 6,849,545 Page <u>3</u> of <u>18</u>

APPLICATION NO.: 09/885,609

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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.: 6,849,545 Page 4 of 18

APPLICATION NO.: 09/885,609

01/66932 42

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INVENTOR(S): Alfred W. MAK, Mei CHANG, Jeong Soo BYUN, Hua CHUNG, Ashok SINHA, Moris KORI

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16/11

Item [56], References Cited, FOREIGN PATENT DOCUMENTS: Please include the following references: COAR

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UNITED STATES PATENT AND TRADEMARK OFFICE

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PATENT NO.: 6,849,545 Page <u>5</u> of <u>18</u>

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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.: 6,849,545 Page <u>6</u> of <u>18</u>

APPLICATION NO.: 09/885,609

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UNITED STATES PATENT AND TRADEMARK OFFICE

CERTIFICATE OF CORRECTION

PATENT NO.: 6,849,545 Page <u>7</u> of <u>18</u>

APPLICATION NO.: 09/885,609

DATED: Feb. 1, 2005

INVENTOR(S): Alfred W. MAK, Mei CHANG, Jeong Soo BYUN, Hua CHUNG, Ashok SINHA, Moris KORI

It is certified that error appears in the above-identified patent and that said Letters Patent are hereby corrected as shown below:

04-273120	09/29/1992	JP	H01L	21/20
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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.: 6,849,545 Page 8 of 18

APPLICATION NO.: 09/885.609

DATED: Feb. 1, 2005

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It is certified that error appears in the above-identified patent and that said Letters Patent are hereby corrected as shown below:

Item [56], References Cited, OTHER PUBLICATIONS: Please include the following references:

Hultman, et al., "Review of the thermal and mechanical stability of TiN-based thin films", Zeitschrift Fur Metallkunde, 90(10) (Oct. 1999), pp. 803-813.

Klaus, et al., "Atomic Layer Deposition of SiO2 Using Catalyzed and Uncatalyzed Self-Limiting Surface Reactions", Surface Review & Letters, 6(3&4) (1999), pp. 435-448.

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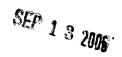
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PATENT NO.: 6,849,545 Page <u>10</u> of <u>18</u>

APPLICATION NO.: 09/885,609

DATED: Feb. 1, 2005

INVENTOR(S): Alfred W. MAK, Mei CHANG, Jeong Soo BYUN, Hua CHUNG, Ashok SINHA, Moris KORI

It is certified that error appears in the above-identified patent and that said Letters Patent are hereby corrected as shown below:

Ritala, et al. "Atomic Layer Epitaxy Growth of TiN Thin Films", J. Electrochem. Soc., 142(8) (Aug. 1995), pp. 2731-737.

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UNITED STATES PATENT AND TRADEMARK OFFICE

CERTIFICATE OF CORRECTION

Page 11 of 18 PATENT NO.: 6,849,545

APPLICATION NO.: 09/885,609

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INVENTOR(S): Alfred W. MAK, Mei CHANG, Jeong Soo BYUN, Hua CHUNG, Ashok SINHA, Moris KORI

It is certified that error appears in the above-identified patent and that said Letters Patent are hereby corrected as shown below:

McGeachin, S., "Synthesis and properties of some β-diketimines derived from acetylacetone, and their metal complexes", Canadian J. of Chemistry, Vol. 46 (1968), pp.1903-1912

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PATENT NO.: 6,849,545

Page 12 of 18

APPLICATION NO.: 09/885.609

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"Applications of Integrated processing", Solid State Technology, US, Cowan Pub., Vol 37, No. 12 (December 1, 1994), pp. 45-47

Kitigawa, et al., "Hydrogen-mediated low temperature epitaxy of Si in plasma-enhanced chemical vapor deposition", Applied Surface Science (2000), pp. 30-34

Lee, et al., "Pulsed nucleation for ultra-high aspect ratio tungsten plugfill", Novellus Systems, Inc. (2001), pp. 1-2.

In the Drawings

Replace all of the drawings (FIGS. 1-10, sheets 1-6) with the formal drawings (FIGS. 1-10, sheets 1-6), copies attached.

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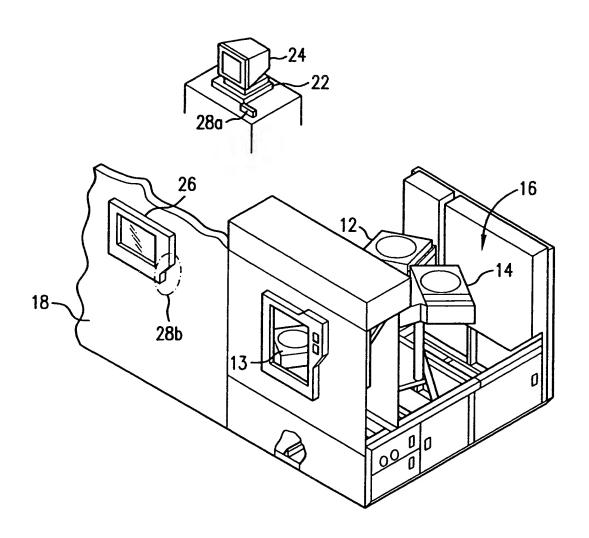


FIG. 1

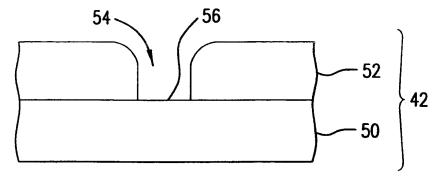


FIG. 3

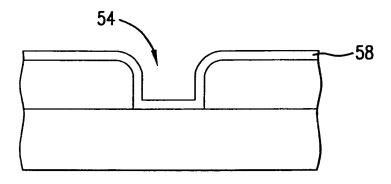


FIG. 4

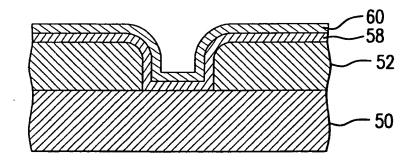


FIG. 5

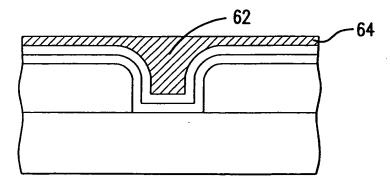


FIG. 6

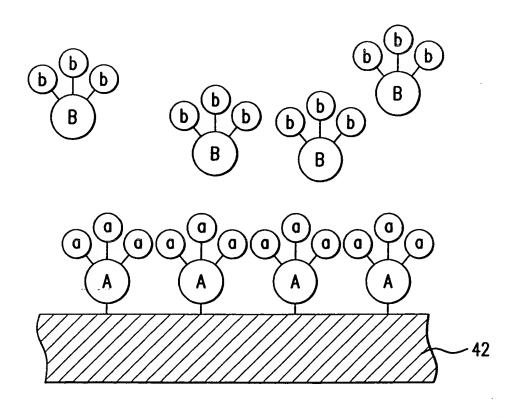


FIG. 7

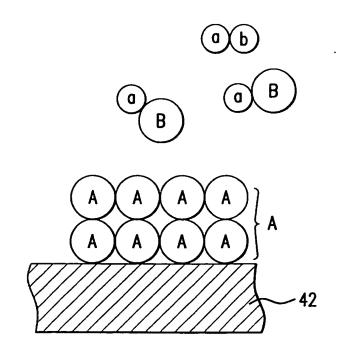
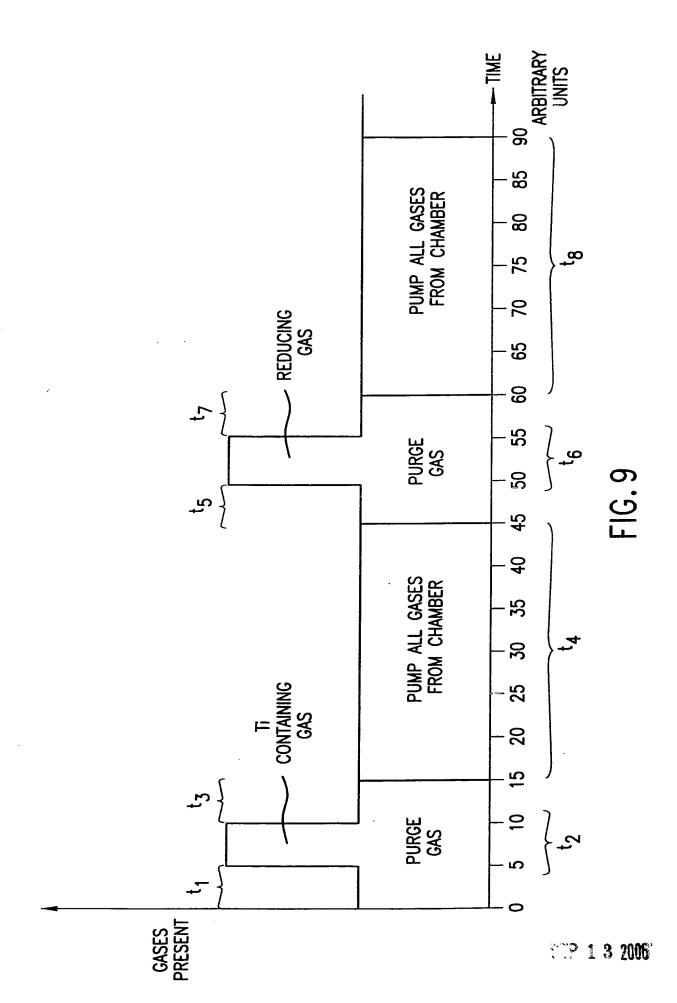
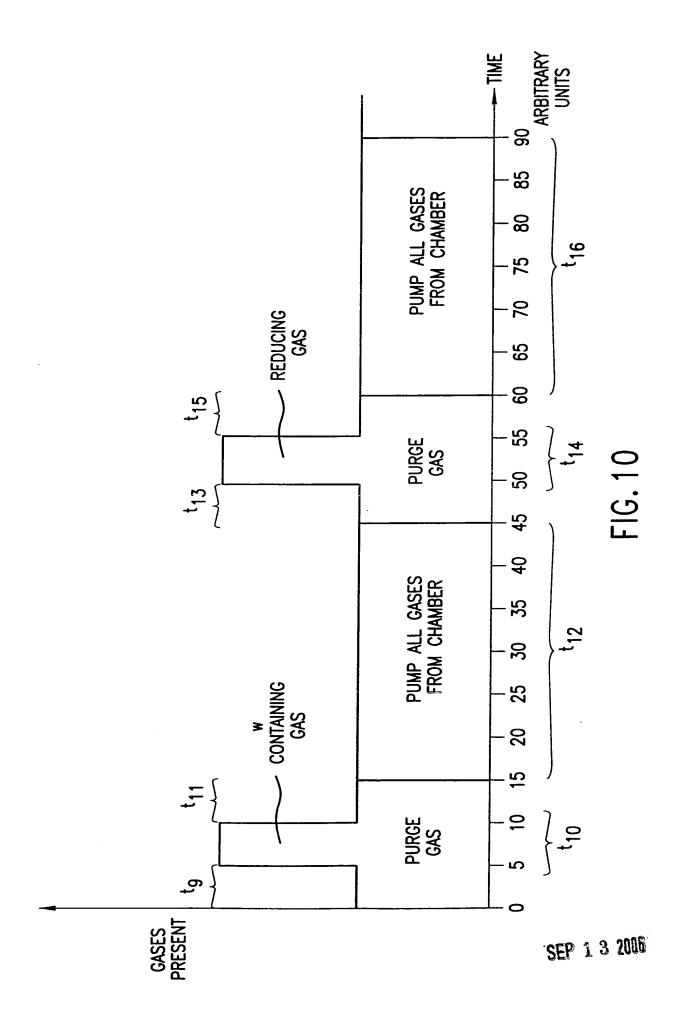
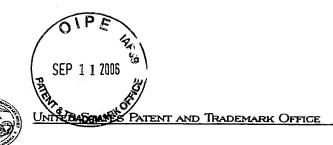


FIG.8











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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/885,609	06/20/2001	Alfred W. Mak	5351/AMI-00-12	5337
32588 7	590 03/14/2003			
	ATERIALS, INC.		EXAM	INER
SANTA CLAR	BLVD. M/S 2061		BERRY, R	LENEE R
JANTA CLAN	A, CA 93030			
			ART UNIT	PAPER NUMBER
			2818	
			DATE MAILED: 03/14/2003	
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Period for Reply		
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET THE MAILING DATE OF THIS COMMUNICATION.	TO EXPIRE 3 MONTH	(S) FROM
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1) Responsive to communication(s) filed on		
	tion is non-final.	
3) Since this application is in condition for allowance	except for formal matters, prosec	cution as to the merits is
closed in accordance with the practice under Ex pa	rte Quayle, 1935 C.D. 11; 453 (D.G. 213.
Disposition of Claims		
4) 🔯 Claim(s) <u>1-54</u>	is/are	pending in the application.
4a) Of the above, claim(s) 20-54	is/are	withdrawn from consideration.
5) Claim(s)	i	s/are allowed.
6) 💢 Claim(s) <u>1-19</u>	i	s/are rejected.
7) Claim(s)	i	s/are objected to.
8) Claims	are subject to restrict	tion and/or election requirement.
Application Papers		
9) The specification is objected to by the Examiner.		
10) The drawing(s) filed on is/are	a) accepted or b) objected	d to by the Examiner.
Applicant may not request that any objection to the d	Irawing(s) be held in abeyance. See	37 CFR 1.85(a).
11) The proposed drawing correction filed on	is: a)□ approved	b) \square disapproved by the Examiner.
If approved, corrected drawings are required in reply	to this Office action.	
12) The oath or declaration is objected to by the Exami	iner.	
Priority under 35 U.S.C. §§ 119 and 120		
13) Acknowledgement is made of a claim for foreign particle.	riority under 35 U.S.C. § 119(a)-	(d) or (f).
a) ☐ All b) ☐ Some* c) ☐ None of:		
1. Certified copies of the priority documents hav	e been received.	
2. Certified copies of the priority documents hav	e been received in Application No	o
3. Copies of the certified copies of the priority de application from the International Bures	ocuments have been received in au (PCT Rule 17.2(a)).	this National Stage
*See the attached detailed Office action for a list of the	e certified copies not received.	
14) ☐ Acknowledgement is made of a claim for domestic	priority under 35 U.S.C. § 119(e	s).
a) The translation of the foreign language provisiona		
15) Acknowledgement is made of a claim for domestic	priority under 35 U.S.C. §§ 120	and/or 121.
Attachment(s)		
1) X Notice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper N	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Informal Patent Application (P	TO-152)
3) Information Disclosure Statement(s) (PTO-1449) Paper No(s).	6) Uther:	

U.S. PATENT DOCUMENTS

		Document Number Country Code-Number-Kind Code	Date MM-YYYY¹	Name	Cla	ssification ²
	A	5,393,565	6/1993	Suzuki et al.	427	255.2
П	В	5,942,799	11/1997	Danek et al.	257	751
	С	6,495,449	5/2000	Nguyen	438	627
	D					
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FOREIGN PATENT DOCUMENTS

	Document Number Country Code-Number-Kind Code	Date MM-YYYY¹	Country	Name	Classification ²
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NON-PATENT DOCUMENTS

Γ		Include, as applicable: Author, Title, Date, Publisher, Edition or Volume, Pertinent Pages
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	x	

^{*} A copy of this reference is not being furnished with this Office action. See MPEP § 707.05(a).

² Classifications may be U.S. or foreign.

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UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450

P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

NOTICE OF ALLOWANCE AND FEE(S) DEE

32588

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08/02/2004

APPLIED MATERIALS, INC. 2881 SCOTT BLVD. M/S 2061 SANTA CLARA, CA 95050 RECD AUG 1 3 2004

EXAMINER

BERRY, RENEE R

ART UNIT

PAPER NUMBER

2818

DATE MAILED: 08/02/2004

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Ĺ	APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
	00/885 600	06/20/2001	Alfred W. Mak	\$351/AMI_00_12	5227

TITLE OF INVENTION: SYSTEM AND METHOD TO FORM A COMPOSITE FILM STACK UTILIZING SEQUENTIAL DEPOSITION TECHNIQUES

APPLN. TYPE	SMALL ENTITY	ISSUE FEE	PUBLICATION FEE	TOTAL FEE(S) DUE	DATE DUE
nonprovisional	NO	\$1330	\$300	\$1630	11/02/2004

THE APPLICATION IDENTIFIED ABOVE HAS BEEN EXAMINED AND IS ALLOWED FOR ISSUANCE AS A PATEN <u>PROSECUTION ON THE MERITS IS CLOSED</u>. THIS NOTICE OF ALLOWANCE IS NOT A GRANT OF PATENT RIGHT THIS APPLICATION IS SUBJECT TO WITHDRAWAL FROM ISSUE AT THE INITIATIVE OF THE OFFICE OR UPO PETITION BY THE APPLICANT. SEE 37 CFR 1.313 AND MPEP 1308.

THE ISSUE FEE AND PUBLICATION FEE (IF REQUIRED) MUST BE PAID WITHIN THREE MONTHS FROM TH MAILING DATE OF THIS NOTICE OR THIS APPLICATION SHALL BE REGARDED AS ABANDONED. THE STATUTORY PERIOD CANNOT BE EXTENDED. SEE 35 U.S.C. 151. THE ISSUE FEE DUE INDICATED ABOV REFLECTS A CREDIT FOR ANY PREVIOUSLY PAID ISSUE FEE APPLIED IN THIS APPLICATION. THE PTOL-85B (O AN EQUIVALENT) MUST BE RETURNED WITHIN THIS PERIOD EVEN IF NO FEE IS DUE OR THE APPLICATION WIL BE REGARDED AS ABANDONED.

HOW TO REPLY TO THIS NOTICE:

I. Review the SMALL ENTITY status shown above.

If the SMALL ENTITY is shown as YES, verify your current SMALL ENTITY status:

A. If the status is the same, pay the TOTAL FEE(S) DUE shown above.

B₁, If the status above is to be removed, check box 5b on Part B - Fèè(s) Transmittal and pay the PUBLICATION FEE (if required) and twice the amount of the ISSUE FEE shown above, or

If the SMALL ENTITY is shown as NO:

A. Pay TOTAL FEE(S) DUE shown above, or

B. If applicant claimed SMALL ENTITY status before, or is n claiming SMALL ENTITY status, check box 5a on Part B - Fee Transmittal and pay the PUBLICATION FEE (if required) and 1 the ISSUE FEE shown above.

II. PART B - FEE(S) TRANSMITTAL should be completed and returned to the United States Patent and Trademark Office (USPTO) w your ISSUE FEE and PUBLICATION FEE (if required). Even if the fee(s) have already been paid, Part B - Fee(s) Transmittal should completed and returned. If you are charging the fee(s) to your deposit account, section "4b" of Part B - Fee(s) Transmittal should completed and an extra copy of the form should be submitted.

III. All communications regarding this application must give the application number. Please direct all communications prior to issuance Mail Stop ISSUE FEE unless advised to the contrary.

IMPORTANT REMINDER: Utility patents issuing on applications filed on or after Dec. 12, 1980 may require payment maintenance fees. It is patentee's responsibility to ensure timely payment of maintenance fees when due.

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SEP 1 1 2006	
A PADEMARKOR	

Application No.	Applicant(s)	
09/885,609	MAK ET AL	
Examiner	Art Unit	
Renee R Berry	2818	

Aladia of Allama hill TRADEMA	09/885,609	MAK ET AL.		
Notice of Allowability	Examiner	Art Unit		
	Renee R Berry	2818		
The MAILING DATE of this communication apperall claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	dication. If not include will be mailed in due	led course. THIS	
 This communication is responsive to 2/26/04. The allowed claim(s) is/are 1-19 and 26-64. 				
3. The drawings filed on 20 June 2001 are accepted by the E				
 Acknowledgment is made of a claim for foreign priority un a) ☐ All b) ☐ Some* c) ☐ None of the: 	der 35 U.S.C. § 119(a)-(d) or (i).			
1. Certified copies of the priority documents have	been received.			
2. Certified copies of the priority documents have		·		
3. Copies of the certified copies of the priority do	cuments have been received in this	national stage applic	ation from the	
International Bureau (PCT Rule 17.2(a)).				
* Certified copies not received:				
5. Acknowledgment is made of a claim for domestic priority up reference was included in the first sentence of the specification.	ation or in an Application Data Sheet		ce a specific	
(a) The translation of the foreign language provisional a		inno a annoifia rafara	noo was included	
 Acknowledgment is made of a claim for domestic priority up in the first sentence of the specification or in an Application 		ince a specific refere	ice was included	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of below. Failure to timely comply will result in ABANDONMENT of	this communication to file a reply control this application. THIS THREE-MO	omplying with the req NTH PERIOD IS NO	uirements noted TEXTENDABLE.	
 A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give 			NOTICE OF	
8. CORRECTED DRAWINGS (as "replacement sheets") mus				
(a) ☐ including changes required by the Notice of Draftspers	son's Patent Drawing Review (PTO	-948) attached		
1) hereto or 2) to Paper No				
(b) ☐ including changes required by the proposed drawing c				
(c) ☐ including changes required by the attached Examiner'	s Amendment / Comment or in the C	Office action of Paper	· No	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the drawi he margin according to 37 CFR 1.121	ngs in the front (not the	ne back) of	
9. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT FOR T	SIT OF BIOLOGICAL MATERIAL OF BIOLOGICAL MA	must be submitted. ATERIAL.	Note the	
Attachment(s)			,	
1 Notice of References Cited (PTO-892)	5☐ Notice of Informal Page			
2 Notice of Draftperson's Patent Drawing Review (PTO-948)	6☐ Interview Summary	(PTO-413), Paper No	D	
3 Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No	3), 7☐ Examiner's Amendr	nent/Comment		
4 Examiner's Comment Regarding Requirement for Deposit	8⊠ Examiner's Stateme	nt of Reasons for All	owance	
of Biological Material	9 □ 0 her			
	· (1)			
	David Nelms			
	Supervisory Patent Examiner			
	Technology Center 2800			

U.S. Patent and Trademark Office PTOL-37 (Rev. 11-03)

Please type a plus sign (+) inside this box PTO/S8/08a (08-03) Approved for use through 07/31/2006, OMB 0651-0031 Frademark Office: U.S. DEPARTMENT OF COMMERCE Amformation unless it displays a valid OMB control number. PADEMARIA 09/885,609 Substitute for form 1449A/PTO Application Number Filing Date June 20, 2001 INFORMATION DISC First Named Inventor Alfred W. Mak et al. STATEMENT BY APPE Group Art Unit 2818 Berry, Renee R. Examiner Name (Use as many sheets as necessary) AMAT/5351/CPI/L/B/PJS Attorney Docket Number Sheet 1 2

Submission Date -

February 26, 2004

of

U.S. PATENT DOCUMENTS								
Examiner	Cite No.1	Document Number	Publication Date	Name of Patentee or	Pages, Columns, Lines, Where			
Initials*	No.	Number-Kind Code ² (F known)	MM-DD-YYYY	Applicant of Cited Document	Relevant Passages or Relevant Figures Appear			
MB	A1	US-5,804,488	09-08-1998	Shih et al.				
W	A2	US-6,218,298 B1	04-17-2001	Hoinkis				
MA	A3	US-6,335,280 B1	01-01-2002	Van der Jeugd				
My	A4	U\$-6,551,929 B1	04-22-2003	Kori et al.				
WID	A5	US-6,599,572 B2	07-29-2003	Saanila et al.				
M	A6	US-6,607,976 B2	08-19-2003	Chen et al.				
ind	A7 .	US-6,632,279 B1	10-14-2003	Ritala et al.				
MU	A8	US-6,686,271 B2	02-03-2004	Raaijmakers et al.				
all	A9	US-2002/0086111 A1	07-04-2002	Byun et al.				
WU .	A10	US-2002/0121241 A1	09-05-2002	Nguyen et al.				
MAD	A11	US-2002/0121342 A1	09-05-2002	Nguyen et al.				
M	A12	US-2003/0013300 A1	01-16-2003	Byun				
11/10	A13	US-2003/0054631 A1	03-20-2003	Raaijmakers et al.				
W	A14	US-2003/0089308 A1	05-15-2003	Raaijmakers				
W	A15	US-2003/0101927 A1	06-05-2003	Raaijmakers				
M	A16	US-2003/0104126 A1	06-05-2003	Fang et al.				
MAS	A17	US-2003/0129826 A1	07-10-2003	Werkhoven et al.				
NA	A18	US-2003/0134508 A1	07-17-2003	Raaijmakers et al.				

		FOR	EIGN PATENT I	DOCUMENTS		
Initials*	Cite	Foreign Patent Document	Publication Date	Name of Patentee or-	Pages, Columns, Lines,	T ⁶
	No.1	Number-Kind Code ² (F latterin) MM-DD-YYYY		Applicant of Cited Document	Where Relevant Passages or Relevant Figures Appear	
MP	B1	WO 02/01628 A2	01-03-2002	Byun et al.		F
NNS	B2	WO 02/45871 A1	06-13-2002	Chiang et al		
	B3			~		
	B4					

Examiner **Date Considered**

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. I Applicants in inque citation designation number (optional), I See Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3), I For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document, akind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. Applicant is to place a check mark here if English language Translation is attached.

This collection of information is required by 37 CFR 1.97 and 1.98. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentially is governed by 35 U.S.C. 122 and 37 CFR 1.4. This collection is estimated to take 2 hours to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the Individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, P.O. Box 1450, Alexandria, VA 22313-1450, DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450. If you need assistance in completing the form, call 1-800-PTO-9199 (1-800-786-9199) and select option 2.



IN ARCHITED STATES PATENT AND TRADEMARK OFFICE

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In re Application of:

Mak, et al.

Serial No.: 09/885,609

Confirmation No.: 5337

1110.. 55

Filed:

June 20, 2001

For:

System and Method to Form a Composite Film Stack Utilizing Sequential Deposition Techniques

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Group Art Unit: 2812

Examiner:

R. Berry

CERTIFICATE OF MAILING 37 CFR 1.8

I hereby certify that this correspondence is being deposited on May _____, 2000 with the United States Postal Service as First Class Mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231.

5/2/02

Date

Signature

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

The Applicants, and the Attorney who signs below on the basis of the information supplied by the inventor and the information in his file, submit herewith patents, publications, or other information of which they are aware, which may be material to the examination of this application and in respect of which there may be a duty to disclose in accordance with 37 CFR § 1.56.

While the information submitted in this Supplemental Information Disclosure Statement may be material pursuant to 37 CFR § 1.56, it is not intended to constitute an admission that any patent, publication, or other information referred to therein is prior art for this invention unless specifically designated as such.

In accordance with 37 CFR § 1.97, this Supplemental Information Disclosure Statement is not to be construed as a representation that a search has been made or that no other possibly material information as defined under 37 CFR § 1.56(a) exists.

The patents and/or publications submitted herewith are set forth on the attached Form PTO-1449.

If the sum of \$180.00 is due under 37 CFR § 1.17(p) pursuant to § 1.97, the Commissioner is hereby authorized to charge this fee, and any other fee necessary to make this submission timely, to the Deposit Account No. 20-0782/APPM/5351/BTP.

Respectfully submitted,

Keith M. Tackett

Registration No. 32,008

MOSER, PATTERSON & SHERIDAN, L.L.P.

2 (2 mg)

3040 Post Oak Blvd., Suite 1500

Houston, TX 77056

Telephone: (713) 623-4844 Facsimile: (713) 623-4846

Attorney for Applicant(s)

J.S. Depart	ment of	Commerce, Patent	and Trademar	k Office	Docket No.		Serial No.
(PTO Form	1449 m	odified)			APPM/535	 	09/885,609
SUPPLEME	NTAL	LIST OF PATENTS	AND PUBLIO	Afions	Applicant		Confirmation No.
CITED BY A	APPLIC	ANI	CEP	1 1 2006	Mak, et al.		5337
(Use severa	al sheets	s if necessary)	\2	\$/	Filing Date		Group
	E	xaminer Berry	(Byrg.	HADEMARK	June 20, 20	001	2812
U.S. Paten	t Docun	nents					
*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A1	4,813,846	03/21/89	Helms	414	744.1	04/29/87
	A2	4,917,556	04/17/90	Stark et al.	414	217	05/26/89
	A3	4,951,601	08/28/90	Maydan, et al.	118	719	06/23/89
	A4	5,000,113	03/19/91	Wang et al.	118	723	12/19/86
	A5	5,028,565	07/02/1991	Chang, et al.	437	192	08/25/1989
	A6	5,173,474	12/22/1992	Connell, et al.	505	1	03/11/1991
	A7	5,186,718	02/16/93	Tepman et al.	29	25.01	04/15/91
	A8	5,205,077	04/27/93	Wittstock	51	165 R	08/28/91
	A9	5,234,561	08/10/93	Randhawa et a	I. 204	192.38	08/25/88
	A10	5,259,881	11/09/93	Edwards, et al.	118	719	05/17/91
	A11	5,286,296	02/15/94	Sato et al.	118	719	01/09/92
•	A12	5,580,380	12/03/1996	Liu, et al.	117	86	01/30/1995
	A13	5,609,689	03/11/97	Kato et al.	118	719	06/03/96
	A14	5,667,592	09/16/97	Boitnott et al.	118	719	04/16/96
	A15	5,674,786	10/07/97	Turner et al.	437	225	06/05/95
	A16	5,695,564	12/09/97	Imahashi	118	719	08/03/95
	A17	5,730,801	03/24/98	Tepman et al.	118	719	08/23/94
	A18	5,788,447	08/04/98	Yonemitsu et a	ıl. 414	217	08/05/96
	A19	5,788,799	08/04/98	Steger, et al.	156	345	06/11/96
	A20	5,801,634	09/01/98	Young et al.	340	635	09/08/97
	A21	5,856,219	01/05/99	Naito et al.	438	241	08/18/97
	A22	5,866,213	02/02/99	Foster et al.	427	573	07/19/97
	A23	5,866,795	02/02/99	Wang et al.	73	1.36	03/17/97
	A24	5,882,165	03/16/99	Maydan et al.	414	217	09/10/97
	A25	5,882,413	03/16/99	Beaulieu et al.	118	719	07/11/97
	A26	5,928,389	07/27/99	Jevtic	29	25.01	10/21/96
					Date Con		

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

U.S. Depar	tment of	f Commerce, Paten	t and Tradema	ark Office	Docket No.		Serial No.
PTO Form	1449 m	nodified)			APPM/535	1	09/885,609
		LIST OF PATENTS	AND PUBLI	CATIONS	Applicant		Confirmation No.:
CITED BY	APPLIC	ANI	Mak, et al.		5337		
Use sever	al sheet	s if necessary)	Filing Date		Group		
	E	Examiner Berry			June 20, 2	001	2812
U.S. Paten	t Docur	ments					
Examiner nitial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	A27	6,051,286	04/18/00	Zhao et al.	427	576	08/22/97
	A28	6,062,798	05/16/00	Muka	414	416	06/13/96
<u> </u>	A29	6,071,808	06/06/00	Merchant et al.	438	633	06/23/99
	A30	6,084,302	07/04/00	Sandhu	257	751	12/26/95
	A31	6,086,677	07/11/00	Umotoy et al.	118	715	06/16/98
	A32	6,110,556	08/29/00	Bang, et al.	428	64.1	10/17/97
	A33	6,117,244	09/12/00	Bang, et al.	118	715	03/24/98
	A34	6,140,237	10/31/00	Chan et al.	438	687	04/19/99
	A35	6,140,238	10/31/00	Kitch	438	687	04/21/99
	A36	6,143,659	11/07/00	Leem	438	688	08/27/98
	A37	6,144,060	11/07/00	Park et al.	257	310	07/31/98
	A38	6,158,446	12/12/00	Mohindra et al.	134	25.4	09/04/98
	A39	6,206,967	03/27/01	Mak, et al.	118	666	06/14/00
	A40	6,271,148	08/07/01	Kao et al.	438	727	10/13/99
	A41	2001/0041250	11/15/01	Werkhoven et al	1. 428	212	03/06/01
Examiner	1		1,		Date Con	sidered	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

J.S. Depart	ment of	Commerce, Pate	ent and Trademari	k Office	Docket No.	l	Serial No.	
PTO Form	1449 m	odified)			APPM/535 Applicant	1	09/885,609	
(PTO Form 1449 modified) SUPPLEMENTAL LIST OF PATENTS AND PUBLICATIONS CITED BY APPLICANT							Confirmation	n No.:
SHEDBY	APPLIC	ANI	Mak, et al.		5337			
Use sever	al sheets	if necessary)	Filing Date		Group			
	E	xaminer Berr	June 20, 2	001	2812			
Foreign Pa	tent Do	cuments						
Examiner		Document	Date	Country	Class	Subclass	Translat	1
nitial		Number					YES	NO
	B1	58-098917	06/13/1983	JP	H01L	21/205		
	B2	58-100419	06/15/1983	JP	H01L	21/20		
	В3	61-035847	02/20/1986	JP	B01J	19/08	\boxtimes	
	B4	61-210623	09/18/1986	JP	H01L	21/205		
	B5	62-069508	03/30/1987	JP	H01L	21/203		
	B6	62-141717	06/25/1987	JP	H01L	21/203		
	B7	62-167297	07/23/1987	JP	C30B	29/40		L
	B8	62-171999	07/28/1987	JP	C30B	29/40		E
	В9	62-232919	10/13/1987	JP	H01L	21/205		
	B10	63-062313	03/18/1988	JP	H01L	21/203		
•	B11	63-085098	04/15/1988	JP	C30B	21/40		
	B12	63-090833	04/21/1988	JP	H01L	21/365		
	B13	63-222420	09/16/1988	JP	H01L	21/205		
	B14	63-222421	09/16/1988	JP	H01L	21/205	\boxtimes	
 	B15	63-227007	09/21/1988	JP	H01L	21/205		
	B16	63-252420	10/19/1988	JP	H01L	21/205		
	B17	63-266814	11/02/1988	JP	H01L	21/205		
	B18	64-009895	01/13/1989	JP	C30B	29/40	\boxtimes	
	B19	64-009896	01/13/1989	JP	C30B	29/40	\boxtimes	
	B20	64-009897	01/13/1989	JP	C30B	29/40		<u> </u>
	B21	64-037832	02/08/1989	JP	H01L	21/205	\boxtimes	
i	B22	64-082615	03/28/1989	JP	H01L	21/205	\boxtimes	
	B23	64-082617	03/28/1989	JP	H01L	21/205	\boxtimes	
	B 24	64-082671	03/28/1989	JP	H01L	29/78	\boxtimes	
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	B25	64-082676	03/28/1989	JP	H01L	29/80	\boxtimes	
	B26	64-090524	04/07/1989	JP	H01L	21/205	\boxtimes	
	B27	01-103982	04/21/1989	JP	C30B	23/08	\boxtimes	
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	B32	01-154511	06/16/1989	JP	H01L	21/20	\boxtimes	
	B33	01-236657	09/21/1989	JP	H01L	29/80	\boxtimes	
	B34	01-245512	09/29/1989	JP	H01L	21/205	\boxtimes	
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:	B53	02-172895	07/04/1990	JP	C30B	29/36	\boxtimes	
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	B56	02-230690	09/13/1990	JP	H05B	33/10	\boxtimes	
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	B74	04-100292	04/02/1992	JP		H01S	3/18		
	B75	04-111418	04/13/1992	JP		H01L	21/205		$\perp \underline{\mathbb{Q}}$
	B76	04-132214	05/06/1992	JP		H01L	21/205		
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	B78	04/151822	05/25/1992	JP		H01L	21/205		
	B79	04-162418	06/05/1992	JP		H01L	21/205	\boxtimes	
	B80	04-175299	06/23/1992	JP		C30B	29/68	\boxtimes	
	B81	04-186824	07/03/1992	JP		H01L	21/205		
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	B84	04-273120	09/29/1992	JP		H01L	21/20		
	B85	04-285167	10/09/1992	JP		C23C	14/54		
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-	B94	05-074724	03/26/1993	JP		H01L	21/205	\boxtimes	
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	B97	05-175143	07/13/1993	JP	H01L	21/205		
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	B101	05-206036	08/13/1993	JP	H01L	21/205		
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	B113	06-177381	06/24/1994	JP .	H01L	29/784	\boxtimes	
-	B114	06-196809	07/15/1994	JP	H01S	3/18	\boxtimes	
	B115	06-222388	08/12/1994	JP	G02F	1/136	\boxtimes	
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	B118	06-252057	09/09/1994	JP	H01L	21/205	\boxtimes	
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	B121	07-086269	03/13/1995	JP	H01L	21/314		
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	B124	09-260786	10/03/1997	JP	H01S	3/18	· 🛛	
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-	B129	11-269652	10/05/1999	JP	C23C	16/44	\boxtimes	
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-	B132	2000-068072	03/03/2000	JP	H05B	33/22		
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	B135	2000-218445	08/08/2000	JP	B23P	6/00		
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	B138	2000-340883	12/08/2000	JP	H01S	5/125		
	B139	2000-353666	12/19/2000	JP	H01L	21/205		
-	B140	2001-020075	01/23/2001	JP	C23C	16/44	\boxtimes	
	B141	2001-152339	06/05/2001	JP	C23C	16/40	\boxtimes	
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	B144	2001-217206	08/10/2001	JP	H01L	21/285	\boxtimes	
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	B146	2001-220294	08/14/2001	JP	C30B	29/20	\boxtimes	L
Examiner			~		Date Con	sidered		

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	B155	98/51838	11/19/1998	wo	C23C	16/06		
	B156	00/11721	03/02/2000	wo	H01L	29/43		
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	C1	Ohba, et al., "Thermal Decomposition of Methy TiN Thin Films", Conference Proceedings, Adv 1993 (1994), pp. 143-149	lhydrazine and Deposit anced Metallization for	tion Properties of CVD ULSI Applications in				
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	C4	Suzuki, et al., "LPCVD-TiN Using Hydrazine ar	and TiCl ₄ ", VMIC Conference (June 8-9, 1993)					
	C5	IBM Tech. Disc. Bull. "Knowledge-Based Dyna Control, (June 1990), pp. 80-84	mic Scheduler in Distri	buted Computer				
	C6	IBM Tech. Disc. Bull. "Multiprocessor and Mult Advanced via Inspection Tools" (May 1992), p	itasking Architecture fo p. 190-191	r Tool Control of the				
	C7	McGeachin, S., "Synthesis and properties of s acetylacetone, and their metal complexes", Capp.1903-1912	ome β-diketimines derivinadian J. of Chemistry	ved from , Vol. 46 (1968),				
	C8	Solanki, et al., "Atomic Layer deposition of Co State Letters, 3(10) (2000), pp. 479-480	oper Seed Layers", Ele	ctrochemical and Solid				
	C9	NERAC.COM Retro Search: Atomic Layer De	position of Copper, date	ed October 11, 2001				
	C10	NERAC.COM Retro Search: Atomic Layer De dated October 2, 2001	position / Epitaxy Alumi	num Oxide Plasma,				
.	C11	NERAC Search abstract of "Atomic Layer dep Barriers", by Rossnagel, et al., J. Vac. Sci. & 1	osition of Ta and Ti for Tech., 18(4) (July 2000)	Interconnect Diffusion				
	C12	Abstracts of articles re atomic layer deposition						
	C13	Abstracts of search results re atomic layer dep	oosition, search dated J	anuary 24, 2002				
	C14	Abstracts of articles re atomic layer deposition	and atomic layer nucle	eation				
	C15	Abstracts of articles re atomic layer deposition	and semiconductors a	nd copper				
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	C16	Abstracts of articles – atomic layer deposition		
	C17	NERAC Search - Atomic Layer Deposition, se		
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<u>,</u>	C20	Choi, et al., "Stability of TiB ₂ as a Diffusion Bar (October 1991), pp. 3062-3067	rrier on Silicon", J. Electi	ochem. Soc. 138(10)
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E UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Mak, et al.

Serial No.: 09/885,609

Confirmation No.: 5337

Filed:

June 20, 2001

For:

System and Method to Form a Composite Film Stack Utilizing Sequential **Deposition Techniques**

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Group Art Unit: 2812

Examiner:

Unknown

CERTIFICATE OF MAILING

37 CFR 1.8

I hereby certify that this correspondence is being deposited on _, 2002 with the United States Postal Service as First Class Mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231.

102 Date

Signature

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

The Applicants, and the Attorney who signs below on the basis of the information supplied by the inventor and the information in his file, submit herewith patents, publications, or other information of which they are aware, which may be material to the examination of this application and in respect of which there may be a duty to disclose in accordance with 37 CFR § 1.56.

While the information submitted in this Supplemental Information Disclosure Statement may be material pursuant to 37 CFR § 1.56, it is not intended to constitute an admission that any patent, publication, or other information referred to therein is prior art for this invention unless specifically designated as such.

In accordance with 37 CFR § 1.97, this Supplemental Information Disclosure Statement is not to be construed as a representation that a search has been made or that no other possibly material information as defined under 37 CFR § 1.56(a) exists.

The patents and/or publications submitted herewith are set forth on the attached Form PTO-1449.

If the sum of \$180.00 is due under 37 CFR § 1.17(p) pursuant to § 1.97, the Commissioner is hereby authorized to charge this fee, and any other fee necessary to make this submission timely, to the Deposit Account No. 20-0782/AMAT/5351/CPI/B/PJS/KMT.

Respectfully submitted,

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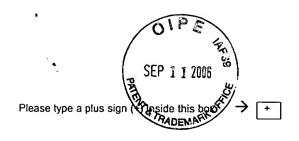
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DOCKET NO.: AMAT/S351 SERIAL NO.: OG 1885 (D)9 FILED: OC 500 (MATERIAL) LMC. INVENTOR: UMALL LET 21	The Patent & Trademark Office acknowledges and has stamped hereon the date of receipt of the items checked below which were mailed AFFIDAVIT AFFIDAVIT AMENDMENT APPLICATION PAPERS - OATH/DECLARATION TOTAL CLS. IND. CLS. FEE \$	SHEET(S) OF DRAWING(S) FORMAL/INFORMAL ASSIGNMENT-RECORDAL FEE \$ BRIEF DAPPEAL NOTICE DECLARATION ISSUE FEE - BASE/BALANCE LETTER - CHARGE DEPOSIT ACCOUNT	TRADEMARK/SERVICEMARK APPLICATION TRADEMARK/SERVICEMARK APPLICATION PETITION PRELIMINARY AMENDMENT INFORMATION DISCLOSURE STATEMENT REQUEST FOR EXTENSION OF TIME RESPONSE TO	SPECIMENS SMALL ENTITY CHECK#

SEP 1 1 2006



PTO/SB/21 (08-00)

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TRANSMITTAL 09/885,609 Application Number **FORM** Filing Date Jun 20, 2001 (to be used for all correspondence after initial filing) First Named Inventor Mak, Alfred W. Group Art Unit 2812 **Examiner Name** Unknown Total Number of Pages in This Submission Attorney Docket Number 5351/AMI-00-12 ENCLOSURES (check all that apply) Assignment Papers After Allowance Communication Fee Transmittal Form (for an Application) to Group Appeal Communication to Board of Fee Attached Drawings (six sheets formal) Appeals and Interferences Appeal Communication to Group Amendment / Reply Licensing-related Papers (Appeal Notice, Brief, Reply Brief) Petition After Final Proprietary Information Petition to Convert to a Affidavits/declaration(s) Status Letter **Provisional Application** Power of Attorney, Revocation Other Enclosure(s) (please Extension of Time Request Change of Correspondence identify below): Address Express Abandonment Request Return Receipt Postcard to Terminal Disclaimer Kenneth C. Brooks Information Disclosure Statement Return Receipt Postcard to Request for Refund Applied Materials, Inc. Certified Copy of Priority **Drawing Transmittal Letter** CD, Number of CD(s) Document(s) Response to Missing Parts/ Remarks Incomplete Application Response to Missing Parts under 37 CFR 1.52 or 1.53 SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT Firm Law Office of Kenneth C. Brooks Individual name Signature Date November 27, 2001 **CERTIFICATE OF MAILING** I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231 on this date: 11-27-2001 Type or printed name Jennifer Bonhan Signature Date November 27, 2001

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IN THE UNITED STATES PATE	NT AND TRADEMARK OFFICE			
Applicants: Mak, et al				
Application No.: 09/885,609 SEP 1 7006				
Application No.: 09/885,609 SEP 1 1 2006	Group Art Unit:			
Filed: 6/20/2001	2812			
Titles Courtem and Mathed to France	P			
Title: System and Method to Form a Composite Film Stack Utilizing	Examiner: Unknown			
Sequential Deposition Techniques	Chalowii			
Attorney Docket No.: 5351/AMI-00-12 Assistant Commissioner for Patents				
Washington, D.C. 20231				
<i>3</i> ,				
DRAWING TRANSMITTAL LETTER				
Sir:				
Enclosed herewith please find:				
() sheets of redlined drawing(s) which indicate proposed changes to the				
	these proposed changes, formal drawing(s) will			
be sublifitied.				
() sheets of corrected formal drawing(s), as required by the Notice of Patent Drawings Objection (PTO-948) which accompanied the Office Action dated				
Drawings Objection (P1O-948	which accompanied the Office Action dated			
() sheets of corrected formal drawing(s), as required by the Notice of Patent Drawing(s) Objection (PTO-948) and approved in the Notice of Allowability				
dated	io) and approved in the rioned of rinowalding			
(√) 6 sheets of formal drawings. I	Please substitute these formal drawings for the			
informal drawings originally fi	Please substitute these formal drawings for the led.			
Evaminar's approval of the entry of those drawin	ag is respectfully requested. No new meeter has			
Examiner's approval of the entry of these drawin been added.	gs is respectfully requested. No new matter has			
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Date of Deposit: NNUMPUY 27, 200	By Ville (1)			
Typed Name: Jennifer Bonham	Kenneth C. Brooks			
Signature: MM MMM	Attorney/Agent for Applicant(s)			
, h	Reg. No. 38,393			
	Date: November 27, 2001 SEP 1 3 2008:			

Telephone No.: 512 527-0104



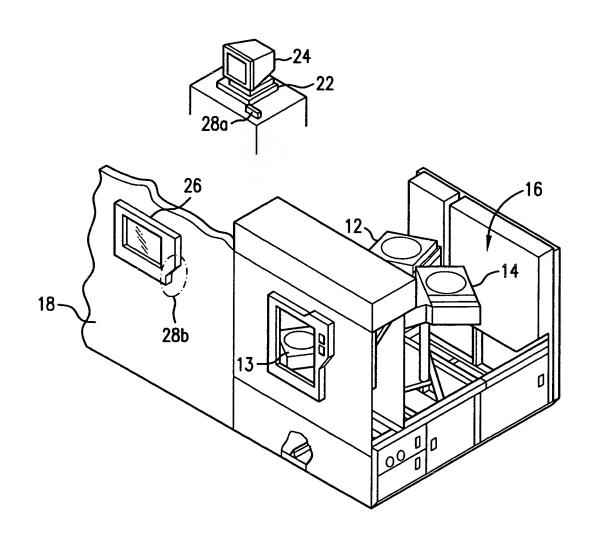
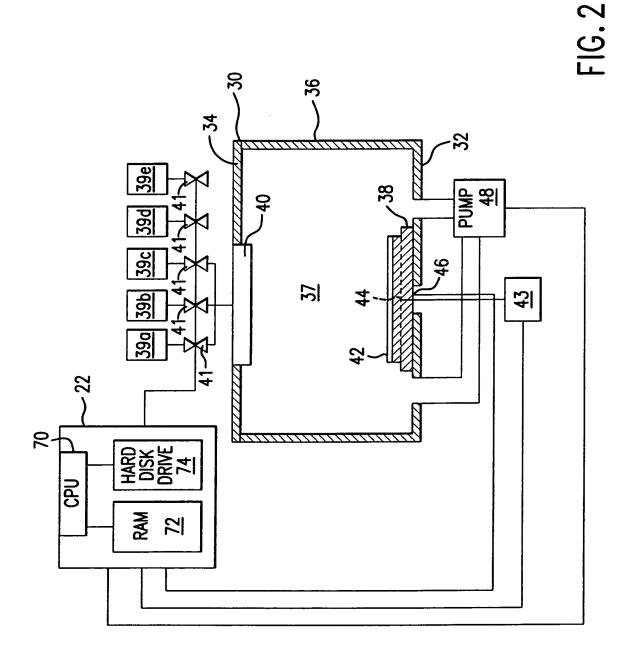


FIG. 1



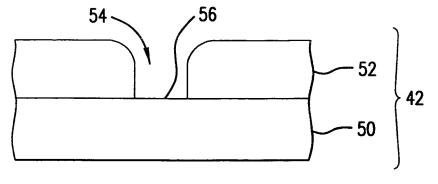


FIG. 3

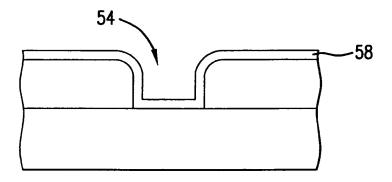


FIG. 4

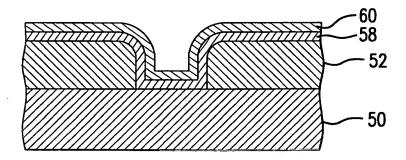


FIG. 5

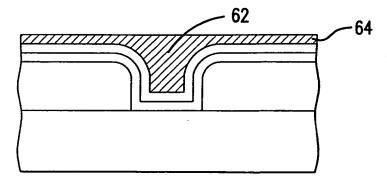


FIG. 6

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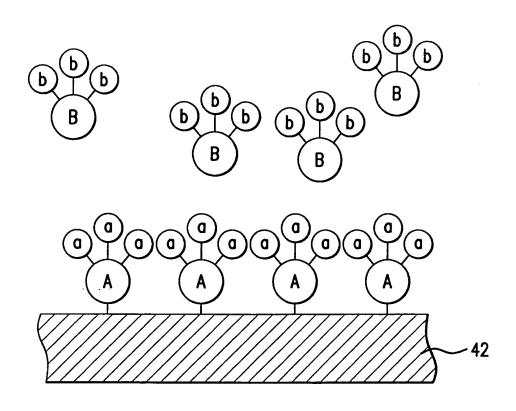


FIG. 7

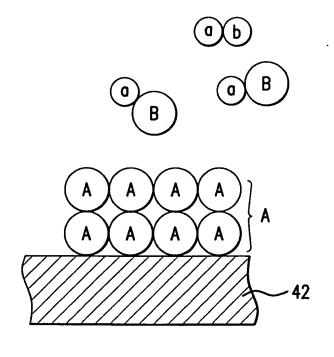
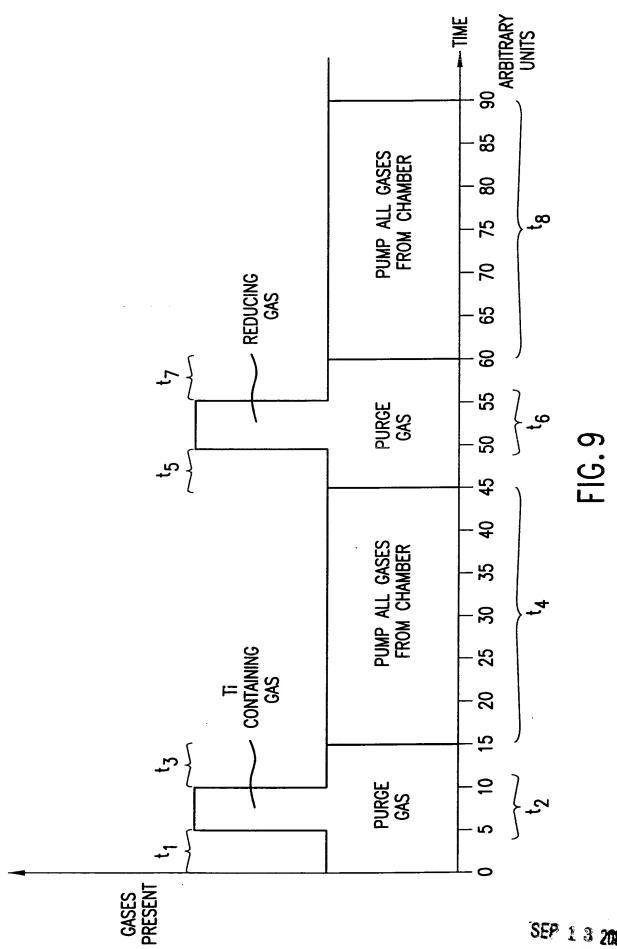
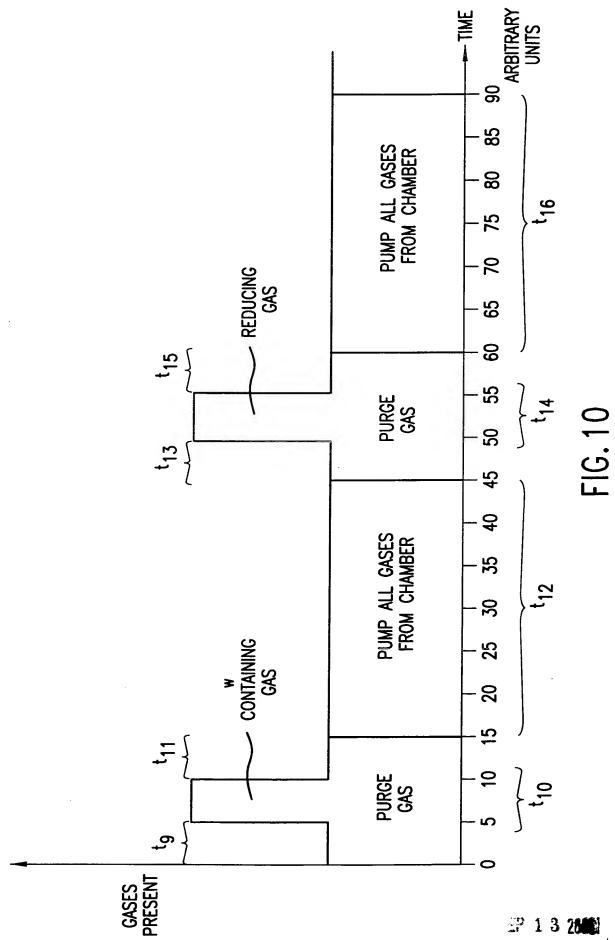


FIG.8





BOX PATENT APPLICATION Commissioner for Patents Washington, D.C. 20231 SEP 1 ! 2006 Applicant: Mak et al. Assignee: Applied Materials. Inc. Title: SYSTEM AND METHOD TO FORM A COMPOSITE FILM STACK UTILIZING SEQUENTIAL DEPOSITION TECHNIQUES Serial No. 09/885,609 Filed: 06/20/01 Attorney Docket No.: 5351/AMI-00-12 X Transmittal Form X Letter to Chief Draftsperson X Six sheets of formal drawings Return Receipt postcard to Kenneth C. Brooks X X Return Receipt postcard to Applied Materials Dated: November 27, 2001

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